

# Growth of MoS<sub>2</sub> flakes via close proximity re-evaporation

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We report the two-steps growth process of MoS<sub>2</sub> nanoflakes using Low-Pressure Chemical Vapor Deposition (LPCVD) technique. The first step consists of synthesis of MoS<sub>2</sub> layer on a c-plane sapphire substrate, which afterward has been re-evaporated at higher temperature to mono/few layers MoS<sub>2</sub> flakes. Such close proximity re-evaporation allows to grow pristine MoS<sub>2</sub> nanoflakes. Atomic Force Microscopy (AFM) data confirmed the synthesis of nanoclusters/flakes with lateral dimensions of over 10 μm and flakes' height of approximately 1.3 nm, proving bi-layer MoS<sub>2</sub>, whereas Transmission electron microscopy (TEM) analysis reveals triangular MoS<sub>2</sub> nanoclusters, with diffraction pattern proving the presence of hexagonal MoS<sub>2</sub>. The Raman data proves the typical modes of high quality MoS<sub>2</sub> nanoflakes. Finally, we present the photocurrent dependence of a MoS<sub>2</sub>-based photoresist under illumination with Light-Emitting Diode (LED) of 405 nm wavelength. The measured current- voltage dependence across various luminous flux outlines the sensitivity of MoS<sub>2</sub> to polarized light.

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